

NI-BASED CORROSION RESISTANT ALLOY POWDER FOR ADDITIVE
MANUFACTURING AND MANUFACTURING METHOD OF ADDITIVE
MANUFACTURING PRODUCT USING SAID POWDER

[Technical Field]

5 [0001]

The present invention relates to, for example, a member used in a corrosive environment such as a wet corrosive environment, and in a semiconductor manufacturing device that handles halogen-containing gases causing severe corrosion such as HCl, Cl₂, HF, F₂, NF₃, ClF₃ and HBr, a member and the like with which these gases come into direct contact, a

10 Ni-based corrosion resistant alloy powder for additive manufacturing required for additive manufacturing of this member, and a method of manufacturing an additive manufacturing product using this powder.

[Background Art]

[0002]

15 Generally, members used in chemical plants, pharmaceutical manufacturing, semiconductor processing and the like are required to have corrosion resistance to withstand a corrosive environment. With regard to this, there is a particularly strong demand to use halogen-containing gases such as HCl, Cl₂, HF, F₂, NF₃, ClF₃ and HBr, which cause a particularly severely corrosive environment, in semiconductor manufacturing process gases, and
20 for that purpose, ultra-pure gases are used. As semiconductors have become finer and higher in definition such as in 3D printing, the allowable size of particles has become smaller and the demand for corrosion resistance of metal materials forming device members and pipe members has become stricter due to the corrosion of metal members with corrosive gases. Therefore, materials have been upgraded from the conventional SUS316L to so-called Ni-based corrosion

resistant alloys containing mainly Ni and about 15 mass% or more of Cr and Mo, and having better corrosion resistance.

[0003]

For example, as shown in Patent Literature 1, it has been proposed to use a Ni-based alloy composed of, in mass% (hereinafter % indicates mass%), Ni: 50% or more, Cr: 14.5 to 16.5%, Mo: 15.0 to 17.0%, W: 3.0 to 4.5%, Fe: 4.0 to 7.0%, and a low carbon content and a low silicon content or a Ni-based alloy composed of Ni: 50% or more, Cr: 20.0 to 22.5%, Mo: 12.5 to 14.5%, W: 2.5 to 3.5%, Fe: 2.0 to 6.0%, and a low carbon content and a low silicon content, as a bellows member of a corrosion resistant valve for ultra-high purity gas control in a semiconductor manufacturing device.

[0004]

In addition, as a bellows member of an ultra-high purity gas control valve used in a ultra-high purity gas manufacturing device and a semiconductor manufacturing device for semiconductor manufacturing processing, Ni-based alloys such as a Ni-based alloy (Ni-based alloy composed of Ni: 58% or more, Cr: 20 to 23%, Fe: 5.0% or less, Mo: 8.0 to 10.0%, Nb (+Ta): 3.15 to 4.15%, and a low carbon content and a low silicon content) known as UNS N06625 (corresponding to Inconel 625 (registered trademark)), a Ni-based alloy (Ni-based alloy composed of Ni: 50% or more, Cr: 14.5 to 16.5%, Mo: 15.0 to 17.0%, W: 3.0 to 4.5%, Fe: 4.0 to 7.0%, and a low carbon content and a low silicon content) known as UNS N10276 (corresponding to Hastelloy C276 (registered trademark)), and a Ni-based alloy (Ni-based alloy composed of Ni: 50% or more, Cr: 20 to 22.5%, Mo: 12.5 to 14.5%, W: 2.5 to 3.5%, Fe: 2.0 to 6.0%, and a low carbon content and a low silicon content) known as UNS N06022 (corresponding to Hastelloy C22 (registered trademark)) have been proposed.

Here, “UNS” indicating an alloy type of a Ni alloy is “Unified Numbering System” defined in ASE HS-1086 and ASTM DS-566, and N06625, N10276, N06022, N07718 (described below), and the like are unique numbers for these registered alloys.

[0005]

5 In addition, in Patent Literature 2, as a material for producing a valve attached to a cylinder for being filled with, storing and transporting halogen compound gases causing severe corrosion such as HCl, HF, and HBr, and additionally halogen-containing gases such as chlorine, fluorine, and bromine, a Ni-based corrosion resistant alloy having a component composition including Cr: 14.5 to 24%, Mo: 12 to 23%, Fe: 0.01 to 6%, Mg: 0.001 to 0.05%, N: 0.001 to 10 0.04%, Mn: 0.05 to 0.5%, Si: 0.01 to 0.1%, Al: 0.01 to 0.5, Ti: 0.001 to 0.5%, Cu: 0.01 to 1.8%, V: 0.01 to 0.5%, and B: 5 to 50 ppm, and optionally further including Ta: more than 1% and 3.4% or less, W: 2 to 5%, and Co: 0.01 to 5%, with the remainder composed of Ni and unavoidable impurities, contents of C, S and P contained as the unavoidable impurities, being adjusted to C: less than 0.05%, S: less than 0.01% and P: less than 0.01%, and having excellent 15 corrosion resistance and mold forgeability has been proposed. Here, it is described that, when mold forging is performed on the Ni-based corrosion resistant alloy, cracks due to mold forging do not occur, and by simply performing minimal final finishing machining, a valve of a cylinder for being filled with halogen-containing gases and halogen compound gases with excellent dimensional accuracy can be manufactured.

20 [0006]

However, the Ni-based alloys in the above conventional technologies are molded into members having a predetermined shape by machining or welding a material of a forged product or a rolled plate, but it is difficult to impart a complex shape with high accuracy to a member by machining, welding or the like.

However, in recent years, additive manufacturing technology called a 3D printing has advanced, and in machining of raw materials such as plates, bars, and pipes, it has become possible to impart complex shapes that would previously have been difficult or impossible to impart.

Thus, in the production of relatively small products that require accuracy, metal powders have also come to be used as raw materials which are applied in additive manufacturing.

[0007]

Among additive manufacturing methods, as additive manufacturing methods in which metal layers are laminated using a metal powder, a method (Powder Bed Fusion method, PBF) in which a process of forming a metal powder layer and a process in which a laser or electron beam is emitted to a predetermined area of the metal powder layer and the metal powder in the area is melted and solidified are alternately repeated, and a method (Directed Energy Deposition method, DED) in which a metal powder is continuously injected at a forward position in a direction in which a laser or electron beam is moved and the supplied metal powder is irradiated with the laser or electron beam and melted and solidified are mainstream. In addition, for the laser or electron beam, a selective laser melting method (SLM), an electron beam melting method (EBM) or the like may be used. In addition, as a laser, for example, a fiber laser can be used.

[0008]

In addition, as the metal powder used for additive manufacturing, for example, a Ni-based ultra heat-resistant alloy powder having a composition corresponding to a Ni-based ultra heat-resistant alloy (nominal composition: Ni-19%Cr-3%Mo-5%(Nb+Ta)-0.9%Ti-0.5%Al-19%Fe) known as UNS N07718 (corresponding to Inconel 718 (registered trademark)) shown in Patent Literature 3 has already been applied,

and is mainly used for producing a member having a complex shape for aircraft that require heat resistance.

[Citation List]

[Patent Literature]

5 [0009]

[Patent Literature 1]

Japanese Examined Patent Publication No. 7-47989

[Patent Literature 2]

Japanese Patent Laid-Open No. 2010-1558

10 [Patent Literature 3]

US Patent No. 3046108

[Summary of Invention]

[Technical Problem]

[0010]

15 Regarding a halogen-containing gas used as a process gas in the semiconductor manufacture technology, a gas with ultra-high purity is used. However, as the wiring width of semiconductor chips has become finer, contamination management has become extremely strict. In addition, chemical plants and pharmaceutical devices often have severely corrosive environments, and even if this is not as severe as with halogen-containing gases, fluids used
20 often contain chlorine ions, and corrosion resistance against chlorine ions with a high concentration is desired.

[0011]

 In addition, the design of constituent members and components thereof has become more complicated, and particularly, it has become necessary to impart not only a shape of an
25 outer surface side but also a shape of an inner side that is in direct contact with a gas.

Therefore, in mold forging and machining, there are demands that exceed the production range thereof.

As described above, in the field of ultra heat-resistant alloys, additive manufacturing can be applied for manufacturing members with complex shapes, but a method of producing a corrosion resistant alloy that can withstand a severely corrosive environment in the above additive manufacturing and a powder suitable for achieving this with high quality have not yet been provided. That is, there is a strong demand for a Ni-based corrosion resistant alloy powder suitable for additive manufacturing, which has excellent corrosion resistance, and with which complex shapes with few defects can be imparted, and there is a strong demand for the development of an additive manufacturing product such as a member for semiconductor manufacturing device using this Ni-based corrosion resistant alloy powder.

[0012]

Here, an objective of the present invention is to provide a Ni-based corrosion resistant alloy powder for additive manufacturing which has excellent corrosion resistance in a severely corrosive environment (for example, a wet environment containing chlorine or a semiconductor process gas environment) and is suitable for reducing the defect rate during additive manufacturing, and a method of manufacturing an additive manufacturing product using this powder.

[Solution to Problem]

[0013]

A Ni-based corrosion resistant alloy powder for additive manufacturing of the present invention is a Ni-based corrosion resistant alloy powder for additive manufacturing, composed of a powder of a Ni-based alloy having a component composition including, in mass%, Cr: 14.5 to 24.5%, Mo: 12.0 to 23.0%, Fe: 0.01 to 7.00%, Co: 0.001 to 2.500%, Mg: 0.010% or less, N: 0.040% or less, Mn: 0.001 to 0.50%, Si: 0.001 to 0.200%, Al: more than 0 and 0.50% or less, Ti:

0.001 to 0.500%, Cu: 0.250% or less, V: 0.001 to 0.300%, B: 0.0001 to 0.0050%, Zr: 0.0001 to 0.0200%, and O: 0.0010 to 0.0300%, with the remainder being Ni and unavoidable impurities, wherein C, S and P are contained as the unavoidable impurities (C: less than 0.05%, S: less than 0.01% and P: less than 0.01%), and wherein a repose angle of the Ni-based alloy powder is 48 degrees or less.

In the Ni-based corrosion resistant alloy powder for additive manufacturing, in a cumulative distribution curve showing the relationship between a particle size and a cumulative volume from a small particle size side obtained by a laser diffraction method, preferably, a particle size d10 corresponding to a cumulative frequency of 10 volume% of the powder is 7 μm or more and 35 μm or less, a particle size d50 corresponding to a cumulative frequency of 50 volume% of the powder is 10 μm or more and 60 μm or less, and a particle size d90 corresponding to a cumulative frequency of 90 volume% of the powder is 20 μm or more and 98 μm or less.

In the Ni-based corrosion resistant alloy powder for additive manufacturing, the uniformity represented by $(d90-d10)/d50$ may be 1.5 or less.

In addition, the component composition may further include, as necessary, at least one of Ta: 2.5% or less and W: 5.0% or less, and preferably, Ta: more than 1.0 and 2.5% or less, W: 2.0 to 5.0%.

[0014]

The present invention is a method of manufacturing a metal additive manufacturing product including performing additive manufacturing using the Ni-based corrosion resistant alloy powder for additive manufacturing as a raw material powder. The additive manufacturing product is preferably a member for semiconductor manufacturing device. In addition, the additive manufacturing in this case is preferably a powder bed fusion method.

[Advantageous Effects of Invention]

[0015]

The Ni-based corrosion resistant alloy powder for additive manufacturing of the present invention is suitable for minimizing the occurrence of defects and has excellent spreading properties during additive manufacturing and has excellent additive manufacturing properties.

5 In addition, additive manufacturing products produced by additive manufacturing (for example, member or component for semiconductor manufacturing device (hereinafter simply referred to as “member for semiconductor manufacturing device”)) have excellent corrosion resistance at least under a wet environment, and also exhibit excellent corrosion resistance under a semiconductor process gas environment with Cl_2 , HBr , NF_3 and the like.

10 In addition, when the member for semiconductor manufacturing device is produced by additive manufacturing using the Ni-based corrosion resistant alloy powder for additive manufacturing, since it is possible to produce a member for semiconductor manufacturing device made of an additive manufacturing product having few defects and high corrosion resistance, the degree of freedom in design of the member for semiconductor manufacturing device increases
15 significantly, the advance can be made in semiconductor manufacturing devices, and industrial effects are excellent.

[Brief Description of Drawings]

[0016]

Fig. 1 shows a schematic view of an additive manufacturing device known in a powder
20 bed fusion method.

Fig. 2 shows a schematic view of an additive manufacturing device known in a directed energy deposition method.

[Description of Embodiments]

[0017]

Hereinafter, one embodiment of the present invention will be described. First, the reason for limiting the component composition of the Ni-based corrosion resistant alloy powder for additive manufacturing of the present invention (hereinafter simply referred to as a Ni-based corrosion resistant alloy powder) will be described in detail, and a particle size distribution and a powder particle size will be then described.

[0018]

[Cr: 14.5% to 24.5% (% is mass%, the same applies hereinafter)]

Cr is effective in improving corrosion resistance in a corrosive environment. For example, when the additive manufacturing product is used as a member for semiconductor manufacturing device, it is effective in improving corrosion resistance against halogen-containing gases such as HCl, Cl₂, HF, F₂, NF₃, ClF₃ and HBr. In particular, if the member for semiconductor manufacturing device is temporarily exposed to the outside air when it is opened, water from the atmosphere may be adsorbed on the metal surface, the adsorbed water and a halogen process gas may be hydrated, and electrochemical corrosion may occur. Cr exhibits corrosion resistance with respect to a hydrated acid particularly in an area with a relatively low concentration. In this case, Cr is required to be contained in an amount of 14.5% or more, but when it is contained in an amount of more than 24.5%, in combination with Mo, phase stability is impaired during additive manufacturing, it is difficult to maintain a single phase, a coarse μ phase is formed, and corrosion resistance deteriorates. Therefore, the content thereof is set to 14.5% to 24.5%.

The upper limit of Cr is preferably 22.5%, and more preferably 20.5%. In addition, the lower limit of Cr is preferably 15.0%, and more preferably 18.0%.

The upper limit values and the lower limit values of the Cr content can be arbitrarily combined. In addition, while the description will be omitted below, the upper limit values and the lower limit values for respective elements to be described below can be arbitrarily combined.

[0019]

[Mo: 12.0% to 23.0%]

Like Cr, Mo is effective in improving corrosion resistance in a corrosive environment. That is, it is effective in improving corrosion resistance against halogen-containing gases such as HCl, Cl₂, HF, F₂, NF₃, ClF₃ and HBr. In particular, if the member for semiconductor manufacturing device is temporarily exposed to the outside air when it is opened, water from the atmosphere may be adsorbed on the metal surface, the adsorbed water and a halogen process gas may be hydrated, and electrochemical corrosion may occur. Mo exhibits corrosion resistance with respect to a hydrated acid particularly in an area with an intermediate to high concentration. In this case, Mo is required to be contained in an amount of 12.0% or more, but if it is contained in an amount of more than 23.0%, since Mo is inferior in oxidation at a high temperature, when the powder is produced by a gas atomization method or the like, an oxide film formed on the surface of each powder becomes thick. The additive manufacturing product produced using this powder is not preferable because defects caused by oxides become significant. Therefore, the content thereof is set to 12.0% to 23.0%.

The upper limit of Mo is preferably 20.5%, and more preferably 19.5%. In addition, the lower limit of Mo is preferably 14.0%, and more preferably 16.0%.

[0020]

[Fe: 0.01% to 7.00%, Co: 0.001% to 2.500%]

Fe and Co have a higher melting point than Ni and have an effect of increasing the molten viscosity. The powder can be produced by, for example, blowing a molten metal in a spray form into an atmospheric gas and quenching it. When a powder is produced by adding Fe and Co, it is possible to easily control the particle size, and it is possible to minimize formation of a fine powder (particle size of less than 5 μm) with which additive manufacturing tends to be difficult. In this case, Fe is required to be contained in an amount of 0.01% or more,

but if it is contained in an amount of more than 7.00%, corrosion resistance with respect to a hydrated acid deteriorates, and thus the content thereof is set to 0.01% to 7.00%.

The upper limit of Fe is preferably 5.50%, and more preferably 1.00%. In addition, the lower limit of Fe is preferably 0.05%, and more preferably 0.10%.

5 Similarly, Co is required to be contained in an amount of 0.001% or more, but if it is contained in an amount of more than 2.500%, this is not preferable because defects caused by shrinkage cavities at the micro level during powder solidification during additive manufacturing become significant. Therefore, the content of Co is set to 0.001 to 2.500%.

The upper limit of Co is preferably 1.000%, and more preferably 0.500%. In addition,
10 the lower limit of Co is preferably 0.005%, and more preferably 0.010%.

[0021]

[N: 0.040% or less, Mg: 0.010% or less, Mn: 0.001% to 0.50%]

When N, Mn and Mg are incorporated together, an effect of minimizing
microsegregation is provided. During additive manufacturing, individual powder particles are
15 instantly melted by a laser, while they are solidified by relative quenching and molded. In this
case, there is a concern that microsegregation may occur. Due to the occurrence of
microsegregation, a dilute area of elements such as Cr and Mo which exhibit corrosion
resistance is formed, and corrosion resistance is overcome in this dilute area. Therefore,
microsegregation should be minimized. N, Mn and Mg have effects of stabilizing a Ni-fcc
20 phase, which is a parent phase and promoting solid-solutionizing of Cr and Mo, and therefore, as
a result, the occurrence of microsegregation during quench solidification is minimized.

However, if N is contained in a very small amount, it has an effect of minimizing
microsegregation during additive manufacturing, but if it is contained in an amount of more than
0.040%, a nitride is formed and the number of defects in the additive manufacturing product
25 increases. Therefore, the content thereof is set to 0.040% or less.

The upper limit of N is preferably 0.030%, and more preferably 0.020%. In addition, the lower limit of the content of N is more than 0, preferably 0.001%, more preferably 0.003%, and still more preferably 0.005%.

Similarly, if Mg is contained in a very small amount, it has an effect of minimizing
5 microsegregation during additive manufacturing, but if it is contained in an amount of more than 0.010%, microsegregation is promoted conversely, and it tends to deteriorate corrosion resistance of the additive manufacturing product. Therefore, the content thereof is set to 0.010% or less.

The upper limit of Mg is preferably 0.0050%, more preferably 0.0030%, and still more
10 preferably 0.0020%. In addition, the lower limit of the content of Mg is more than 0, preferably 0.0001%, more preferably 0.0003%, and still more preferably 0.0005%.

On the other hand, when the content of Mn is less than 0.001%, there is no effect of minimizing microsegregation during additive manufacturing, and when it is contained in an amount of more than 0.50%, microsegregation is promoted conversely, and for example,
15 corrosion resistance of the additive manufacturing product with respect to a semiconductor process gas tends to deteriorate. Therefore, the content thereof is set to 0.001% to 0.50%.

The upper limit of Mn is preferably 0.40%, and more preferably 0.35%. In addition, the lower limit of Mn is preferably 0.005%, more preferably 0.006%, and still more preferably 0.007%.

20 Here, it is confirmed that the effects of these three elements are not the same, and when the three elements are not contained in a predetermined range at the same time, there is no effect of minimizing microsegregation.

[0022]

[Si: 0.001% to 0.200%, Al: more than 0 and 0.50% or less, Ti: 0.001% to 0.500%]

Si, Al and Ti have an effect of improving the cleanliness in the alloy when added as deoxidizing agents. Thereby, a powder and another powder are smoothly bonded during additive manufacturing, and as a result, the occurrence of defects in the additive manufacturing product is minimized.

5 If Si is contained in an amount of 0.001% or more, the effect thereof is exhibited, but if it is contained in an amount of more than 0.200%, segregation occurs in the grain boundaries and the corrosion resistance tends to deteriorate. Therefore, the content of Si is set to 0.001% to 0.200%.

The upper limit of Si is preferably 0.100%, and more preferably 0.010%. In addition,
10 the lower limit of Si is preferably 0.002%, and more preferably 0.005%.

Similarly, if Al is contained in a very small amount, a cleaning effect in the alloy is exhibited, but if it is contained in an amount of more than 0.50%, oxide formation during additive manufacturing becomes significant, and the number of defects in the additive manufacturing product increases. Therefore, the content of Al is set to more than 0 and 0.50%
15 or less.

The upper limit of Al is preferably 0.40%, and more preferably 0.30%. In addition, the lower limit of Al is preferably more than 0, preferably 0.001%, more preferably 0.003%, and still more preferably 0.005%.

Similarly, if Ti is contained in an amount of 0.001% or more, a cleaning effect in the
20 alloy is exhibited, but if it is contained in an amount of more than 0.500%, oxide formation during additive manufacturing becomes significant, and the number of defects in the additive manufacturing product increases. Therefore, the content of Ti is set to 0.001% to 0.500%.

The upper limit of Ti is preferably 0.200%, and more preferably 0.100%. In addition, lower limit of Ti is preferably 0.003%, and more preferably 0.005%.

25 [0023]

[Cu: 0.250% or less]

Cu is effective in improving corrosion resistance in a reducing wet corrosive environment with hydrochloric acid and hydrofluoric acid. Therefore, it is effective against electrochemical corrosion caused by the process gas and water adsorbed on the metal surface.

- 5 If Cu is contained in a very small amount, the effect is exhibited, but if it is contained in an amount of more than 0.250%, oxides on the surface of the produced powder make the defects in the additive manufacturing product significant. Therefore, the content of Cu is set to 0.250% or less.

- The upper limit of Cu is preferably 0.100%, and more preferably 0.010%. In addition,
10 the lower limit of the content of Cu is more than 0, preferably 0.001%, more preferably 0.002%, and still more preferably 0.005%.

[0024]

[V: 0.001% to 0.300%]

- V is effective in minimizing the formation of powder particles with a large diameter
15 when the powder is produced in the form of a mist from the molten metal. A powder with a diameter that is too large is not preferable because in this case defects become significant due to large gaps between particles during additive manufacturing. Therefore, large powder particles are removed during powder classification, but the yield (powder yield) thereby decreases, which causes a problem in industrial production. Unless V is added in an amount of 0.001% or more,
20 an effect of minimizing coarse powder is not obtained, but if it is contained in an amount of more than 0.300%, this is not preferable because micronization proceeds conversely, and the required yield (powder yield) of the particle size is also reduced. Therefore, the content of V is set to 0.001% to 0.300%.

- The upper limit of V is preferably 0.200%, and more preferably 0.100%. In addition,
25 the lower limit of V is preferably 0.003%, and more preferably 0.005%.

[0025]

[B: 0.0001% to 0.0050%, Zr: 0.0001% to 0.0200%]

B and Zr become nuclei in the solidification process and are effective in preventing the occurrence of shrinkage cavities. When the additive manufacturing product is molded, the process of melting and solidifying individual powder particles is repeated, but when shrinkage cavities occur in the solidification process, these defects become the source of particle generation, and thus it is inappropriate for an additive manufacturing product used as a member or component for the semiconductor manufacturing device.

If B is contained in an amount of 0.0001% or more, an effect of preventing the occurrence of shrinkage cavities is exhibited, but if it is contained in an amount of more than 0.0050%, segregation occurs in the grain boundaries and the corrosion resistance tends to deteriorate. Therefore, the content of B is set to 0.0001% to 0.0050%.

The upper limit of B is preferably 0.0040%, and more preferably 0.0030%. In addition, the lower limit of B is preferably 0.0002%, and more preferably 0.0005%.

Similarly, if Zr is contained in an amount of 0.0001% or more, an effect of preventing the occurrence of shrinkage cavities is exhibited, but if it is contained in an amount of more than 0.0200%, as in B, segregation occurs in the grain boundaries and the corrosion resistance tends to deteriorate. Therefore, the content of Zr is set to 0.0001% to 0.0200%.

The upper limit of Zr is preferably 0.0100%, more preferably 0.0080%, and still more preferably 0.0060%. In addition, the lower limit of Zr is preferably 0.0005%, and more preferably 0.0008%.

Here, it is confirmed that the effects of these two elements are not the same, and when the two elements are not contained in a predetermined range at the same time, there is no effect of preventing the occurrence of shrinkage cavities.

[0026]

[O: 0.0010% to 0.0300%]

O is mainly instantly combined with Cr in a high temperature state immediately after solidification in the spraying process of the molten metal during powder production, and forms a very thin and strong oxide film on the powder surface, and thereby it has an effect of minimizing further progress of oxidation. Thereby, the amount of powder-derived oxides incorporated as a foreign substance into the additive manufacturing product is reduced to a very low level. If O is contained in an amount of 0.0010% or more, the effect is exhibited, but if it is contained in an amount of more than 0.0300%, oxides on the surface of the powder make the defects in the additive manufacturing product significant. Therefore, the content of O is set to 0.0010% to 0.0300%.

The upper limit of O is preferably 0.0200%, and more preferably 0.0100%. In addition, the lower limit of O is preferably 0.0020%, and more preferably 0.0050%.

[0027]

[Ta: 2.5% or less]

Ta is effective in improving corrosion resistance against a reducing acid or an oxidizing acid and corrosion resistance against pitting corrosion and crevice corrosion, and thus it is added as necessary. If added, 2.5% or less may be added. Here, if it is contained in an amount of more than 1.0%, an effect of significantly improving corrosion resistance is exhibited, but if it is contained in an amount of more than 2.5%, the amount of oxides formed on the powder surface during powder production increases, and thereby defects in the laminated product become significant. Therefore, the content is preferably more than 1.0% and 2.5% or less.

The upper limit of Ta is preferably 2.3%, and more preferably 2.2%. In addition, the lower limit of Ta is preferably 1.1%, and more preferably 1.2%.

[0028]

[W: 5.0% or less]

Like Mo, W is effective in improving corrosion resistance against a reducing acid, and at the same time, it increases the melting point, and increases the viscosity of the molten metal, which makes it easy to control the particle size when the powder is produced. Simultaneously, it can minimize formation of a fine powder (particle size of less than 5 μm) with which additive manufacturing tends to be difficult, and thus it is added as necessary. If added, 5.0% or less may be added. In order to obtain a greater effect, it is preferable to add 2.0% or more. However, if it is contained in an amount of more than 5.0%, the melting point becomes higher than necessary, and thus the powder tends to become coarse, and the yield (powder yield) for classifying an appropriate powder diameter decreases. Therefore, the content is preferably 2.0% to 5.0%.

The upper limit of W is preferably 4.9%, and more preferably 4.5%. In addition, the lower limit of W is preferably 2.2%, and more preferably 2.5%.

[0029]

[Unavoidable impurities: C: less than 0.05%, S: less than 0.01%, P: less than 0.01%]

The remainder is Ni and unavoidable impurities. As unavoidable impurities, C forms carbides with Cr near crystal grain boundaries, and increases deterioration of corrosion resistance. Therefore, the content of C is set to less than 0.05%. In addition, S and P segregate at the grain boundaries and cause cracks at a high temperature, and thus the amount thereof should be minimized to less than 0.01%.

In addition, the content of these unavoidable impurities is preferably small and may be 0%.

[0030]

The component composition of the Ni-based corrosion resistant alloy powder for additive manufacturing of the present invention can be determined by the following measurement method.

As will be described below in examples, the powder for additive manufacturing after classification is melted in an appropriate aqueous solution, the aqueous solution is subjected to high frequency inductively coupled plasma (ICP) analysis, and the content of a predetermined component is measured.

5 Here, the content of C and S is determined using a carbon sulfur analysis device, and the content of N and O is determined using an oxygen nitrogen analysis device by performing gas analysis according to a combustion method.

[0031]

10 The Ni-based corrosion resistant alloy powder of the present invention is used for the above additive manufacturing (additive manufacturing). For example, in the additive manufacturing by a powder bed fusion method (hereinafter referred to as a powder bed method), it is necessary to spread the metal powder on the stage bed to form a flat and uniform metal powder layer having a thickness of about 20 to 100 μm , and repeat this operation. Surface roughness and defects are affected according to powder properties of the metal powder in this case. Therefore, it is required that the metal powder be smoothly supplied, and flow efficiently when squeegeed, and spread to a flat and uniform thickness. That is, good fluidity and good spreading properties are required. Hereinafter, the powder properties, the fluidity, and the spreading properties of the Ni-based corrosion resistant alloy powder will be described.

[0032]

20 [Fluidity]

 The fluidity of the Ni-based corrosion resistant alloy powder is evaluated by a repose angle according to JIS R9301-2-2. When the repose angle exceeds 48 degrees, the fluidity is poor and spreading properties are poor. The repose angle needs to be 48 degrees or less, and is preferably 40 degrees or less. The lower limit is not particularly limited and can be, for example, 20 degrees or more.

[0033]

[Particle size distribution]

The particle size distribution of the Ni-based corrosion resistant alloy powder of the present invention is determined by a laser diffraction method using a laser diffraction type particle size distribution measurement device. In the cumulative distribution curve showing the relationship between the particle size and the cumulative volume from the small particle size side, when a particle size d10 corresponding to a cumulative frequency of 10 volume%, a particle size d50 corresponding to a cumulative frequency of 50 volume%, and a particle size d90 corresponding to a cumulative frequency of 90 volume% are measured, d10 is 7 μm or more and 35 μm or less. The lower limit of d10 is preferably 10 μm . The upper limit of d10 is preferably 25 μm . The upper limit values and the lower limit values of the d10 can be arbitrarily combined. Although the description is omitted, the same applies to the following d50 and d90.

d50 is 10 μm or more and 60 μm or less. The lower limit of d50 is preferably 20 μm . The upper limit of d50 is preferably 40 μm .

d90 is 20 μm or more and 98 μm or less. The lower limit of d90 is preferably 40 μm . The upper limit of d90 is preferably 80 μm .

Particles that are too small cause the powder layer to be frayed and biased, which results in poor coatability. On the other hand, particles that are too large may affect defects and surface roughness due to concerns about the melted residue due to insufficient power of the laser. When the above particle size distribution is provided or when the numerical value requirements for d50 are simply satisfied, the powder layer can be repeatedly spread to a flat and uniform thickness. Therefore, good spreading properties are obtained. Here, a Ni-based alloy powder having the above particle size distribution is suitable for SLM.

[0034]

[Uniformity of particle size]

In addition, in the present invention, a numerical value represented by $(d_{90}-d_{10})/d_{50}$ is defined as uniformity. When the uniformity of the Ni-based corrosion resistant alloy powder is 1.5 or less, the spreading properties are good, and the uniformity is preferably 1.2 or less, and more preferably 1.1 or less. For the lower limit, the value of the uniformity can be reduced by classification or the like, but the powder yield and the productivity are lowered, for example, 0.8 or more is preferable and 0.9 or more is more preferable. For the uniformity represented by the above formula, it can be said that, when the numerical value is smaller, the width of the particle size distribution is narrower, the variation is smaller and the median diameter is uniform. In addition, it can be said that, as the value of the uniformity is smaller, the cohesiveness is weaker, the fluidity is higher, and spreading properties are favorable, and this is suitable for additive manufacturing.

As described above, when the range of the above repose angle and/or the above particle size distribution and uniformity are provided, the Ni-based corrosion resistant alloy powder of the present invention has favorable fluidity and excellent spreading properties. As a result, it is possible to reduce the defect rate during additive manufacturing and it is possible to obtain an additive manufacturing product in which the occurrence of defects is minimized

[0035]

[Powder particle size]

Additive manufacturing is a molding method in which individual powder particles are repeatedly melted and solidified to impart a shape. However, if the particle size of the Ni-based corrosion resistant alloy powder is less than 5 μm , it is difficult to obtain a volume required for one melting and solidification, and thus it is difficult to obtain a sound additive manufacturing product. If the amount of the powder having a particle size of less than 5 μm is small, the powder yield is improved, and it contributes to reduction of the defect rate. On the

other hand, if the particle size of the Ni-based corrosion resistant alloy powder exceeds 100 μm , a volume required for one melting and solidification is too large and it is difficult to obtain a sound additive manufacturing product. Since the amount of the powder having a particle size of more than 100 μm is small, power shortage of the laser is minimized, which contributes to reduction of the defect rate. Among these, in the powder bed method using SLM, it is preferable to use a Ni-based corrosion resistant alloy powder having a particle size distribution range of 5 μm or more and 100 μm or less. The particle size distribution range of the Ni-based corrosion resistant alloy powder is more preferably a range of 20 μm or more and 80 μm or less.

[0036]

In addition, the Ni-based corrosion resistant alloy powder can be produced using a gas atomization method, a water atomization method, a jet atomization method or the like. The particle shape of the Ni-based corrosion resistant alloy powder is preferably spherical, and the powder is more preferably produced by the gas atomization method.

[0037]

The Ni-based corrosion resistant alloy powder for additive manufacturing of the present invention can be suitably used for the powder bed method (SLM) using a laser. For example, in an additive manufacturing device shown in Fig. 1, the Ni-based corrosion resistant alloy powder for additive manufacturing of the present invention is supplied, a powder layer having a thickness of 20 to 100 μm , and preferably 30 to 60 μm is formed by squeezing, a high energy laser with an output adjusted to, for example, 400 W or less, is emitted to an area in which the powder is provided, and the alloy powder is selectively melted and bonded. The scanning speed in this case may be adjusted to, for example, 7,000 mm/s or less. When the melting and solidification operation is repeated in this manner, additive manufacturing products having a desired shape can be additive manufactured.

According to additive manufacturing using the Ni-based corrosion resistant alloy powder for additive manufacturing of the present invention, there are very few defects, and a valve member of a cylinder for being filled with halogen-containing gases and halogen compound gases, which exhibits excellent corrosion resistance under a wet environment or semiconductor process gas environment, a gas contact member in a mass flow meter, a gas block member, and a member for semiconductor manufacturing device such as gas fittings can be obtained.

In addition, as the additive manufacturing device, not only the device shown in Fig. 1, but also a directed energy deposition method additive manufacturing device shown in Fig. 2 can be used depending on the shape of the additive manufacturing product and the like. The model of the additive manufacturing device and the like are not particularly limited.

[0038]

Next, examples of the present invention will be described.

Examples

[0039]

(Example 1)

Melted raw materials were prepared and melted using a high frequency vacuum melting furnace, and about 10 kg of each base alloy was prepared. In an argon atmosphere, using a gas atomization method, raw powders for obtaining the Ni-based corrosion resistant alloy powder for additive manufacturing having component compositions shown in Table 1 to Table 4 were prepared. Here, regarding C, S, and P corresponding to unavoidable impurities, the content of C was less than 0.05%, and the contents of S and P were less than 0.01%.

The raw gas atomized powders obtained above were directly classified into powders having a particle size of 20 to 80 μm for additive manufacturing and other powders using a plurality of sieves.

In Example 1, additive manufacturing was performed by a powder bed method (SLM) using a laser, and the corrosion resistance (wet environment and semiconductor process gas) of the Ni-based corrosion resistant alloy powder was confirmed. Here, in the tables, No. 41 to No. 48, No. 52, No. 54 to No. 60, No. 62 to No. 67, and No. 69 to No. 70 marked with * are examples outside the range of the composition according to the present invention. Here, there was no conventional product as the Ni-based corrosion resistant alloy powder for additive manufacturing.

[0040]

[Table 1]

10 (Continued in Table 2)

Alloy powder	Component composition (mass%)								
	Cr	Mo	Fe	Co	Mg	N	Mn	Si	Al
1	18.8	18.7	0.34	0.011	0.0018	0.008	0.011	0.013	0.31
2	21.2	13.4	4.55	0.732	0.0013	0.012	0.161	0.031	0.32
3	15.4	16	6.04	1.214	0.0043	0.023	0.490	0.040	0.34
4	22.8	15.7	0.56	0.009	0.0004	0.027	0.132	0.013	0.21
5	20.4	16.3	0.14	0.152	0.0007	0.026	0.231	0.011	0.28
6	15.2	22.2	0.97	0.621	0.0008	0.022	0.244	0.026	0.24
7	14.6	15.4	0.62	0.399	0.0018	0.010	0.063	0.044	0.13
8	23.9	14.3	1.94	0.015	0.0024	0.027	0.162	0.016	0.08
9	22.5	12.1	4.04	0.062	0.0008	0.006	0.236	0.020	0.40
10	18.6	22.9	2.71	0.007	0.0021	0.012	0.325	0.046	0.23
11	16.3	14.6	0.01	0.714	0.0018	0.012	0.195	0.028	0.40
12	15.8	16.7	6.98	0.593	0.0007	0.012	0.355	0.008	0.11
13	19.8	15.8	2.03	0.001	0.0025	0.028	0.074	0.094	0.30
14	16.9	15.5	3.97	2.495	0.0022	0.027	0.290	0.081	0.27
15	20.2	14.6	4.46	0.419	0.0001	0.023	0.054	0.048	0.38
16	19.8	20.2	0.06	0.920	0.0049	0.010	0.091	0.040	0.31
17	21.0	18.8	0.62	0.970	0.0006	0.001	0.179	0.005	0.04
18	17.4	19.9	1.95	0.035	0.0028	0.040	0.248	0.037	0.31
19	18.4	19.2	0.54	0.469	0.0012	0.022	0.005	0.048	0.08
20	16.3	20.3	0.41	0.546	0.0022	0.005	0.495	0.066	0.11
21	15.7	14.8	4.23	0.279	0.0018	0.017	0.012	0.001	0.08
22	19.2	19.9	1.72	0.204	0.0029	0.029	0.343	0.199	0.30
23	22.1	18.4	1.19	0.171	0.0026	0.013	0.203	0.013	0.01
24	18.0	19.9	2.43	0.077	0.0024	0.027	0.326	0.021	0.49
25	21.7	19.7	3.87	0.806	0.0006	0.004	0.056	0.052	0.34
26	19.9	18.7	0.58	0.609	0.0017	0.019	0.045	0.063	0.08

27	20.8	16.2	2.24	0.644	0.0028	0.015	0.141	0.048	0.21
28	20.6	14.2	2.03	0.662	0.0026	0.009	0.236	0.007	0.30
29	17.0	18.4	2.31	0.812	0.0005	0.028	0.359	0.036	0.11
30	17.7	15.7	2.10	0.256	0.0013	0.024	0.123	0.070	0.39
31	21.6	15.8	2.54	0.723	0.0016	0.012	0.273	0.009	0.24
32	18.5	19.8	2.79	0.110	0.0020	0.016	0.036	0.026	0.21
33	19.1	14.1	0.82	0.785	0.0008	0.026	0.197	0.097	0.08
34	15.9	15.8	3.79	0.565	0.0008	0.021	0.090	0.073	0.33
35	19.7	14.1	3.43	0.242	0.0010	0.019	0.191	0.028	0.24
36	15.3	16.5	4.45	0.244	0.0005	0.028	0.361	0.064	0.24
37	18.5	14.5	0.38	0.477	0.0013	0.011	0.305	0.040	0.40
38	20.5	17.2	3.51	0.927	0.0016	0.004	0.138	0.050	0.04
39	18.8	14.7	1.49	0.372	0.0003	0.016	0.349	0.015	0.34
40	18.3	16.0	4.06	0.700	0.0003	0.019	0.356	0.004	0.14

[0041]

[Table 2]

(Continued from Table 1)

Alloy powder	Component composition (mass%)								
	Ti	Cu	V	B	Zr	O	Ta	W	Ni+ unavoidable impurities
1	0.012	0.031	0.008	0.0007	0.0062	0.0012	1.8	-	Remainder
2	0.014	0.033	0.043	0.0006	0.0083	0.0154	-	2.9	Remainder
3	0.009	0.021	0.007	0.0007	0.0064	0.0176	-	3.7	Remainder
4	0.006	0.027	0.103	0.0007	0.0071	0.0157	-	-	Remainder
5	0.063	0.035	0.088	0.0012	0.0086	0.0174	-	3.9	Remainder
6	0.041	0.044	0.109	0.0016	0.0010	0.0166	-	-	Remainder
7	0.062	0.058	0.078	0.0024	0.0034	0.0176	-	-	Remainder
8	0.165	0.043	0.037	0.0003	0.0074	0.0174	-	-	Remainder
9	0.163	0.046	0.181	0.0018	0.0043	0.0032	-	-	Remainder
10	0.188	0.060	0.153	0.0037	0.0030	0.0089	-	-	Remainder
11	0.183	0.066	0.053	0.0038	0.0073	0.0092	-	-	Remainder
12	0.070	0.081	0.115	0.0025	0.0047	0.0178	-	-	Remainder
13	0.031	0.057	0.196	0.0029	0.0049	0.0107	-	-	Remainder
14	0.134	0.030	0.105	0.0020	0.0035	0.0199	-	-	Remainder
15	0.049	0.092	0.108	0.0010	0.0018	0.0098	-	-	Remainder
16	0.101	0.073	0.149	0.0023	0.0061	0.0157	-	-	Remainder
17	0.052	0.056	0.138	0.0010	0.0046	0.0130	-	-	Remainder
18	0.177	0.094	0.016	0.0025	0.0072	0.0089	-	-	Remainder
19	0.066	0.043	0.018	0.0014	0.0020	0.0112	-	-	Remainder
20	0.133	0.057	0.076	0.0037	0.0072	0.0112	-	-	Remainder
21	0.113	0.011	0.098	0.0033	0.0047	0.0029	-	-	Remainder
22	0.136	0.083	0.120	0.0021	0.0067	0.0054	-	-	Remainder
23	0.096	0.020	0.135	0.0021	0.0023	0.0113	-	-	Remainder

24	0.181	0.058	0.025	0.0012	0.0071	0.0145	-	-	Remainder
25	0.001	0.028	0.162	0.0029	0.0043	0.0156	-	-	Remainder
26	0.496	0.078	0.171	0.0030	0.0079	0.0171	-	-	Remainder
27	0.019	0.001	0.127	0.0026	0.0016	0.0109	-	-	Remainder
28	0.038	0.248	0.165	0.0024	0.0066	0.0142	-	-	Remainder
29	0.088	0.098	0.001	0.0013	0.0045	0.0157	-	-	Remainder
30	0.190	0.020	0.298	0.0039	0.0023	0.0155	-	-	Remainder
31	0.130	0.047	0.153	0.0001	0.0073	0.0179	-	-	Remainder
32	0.073	0.076	0.097	0.0049	0.0045	0.0165	-	-	Remainder
33	0.030	0.074	0.182	0.0033	0.0001	0.0134	-	-	Remainder
34	0.046	0.033	0.117	0.0025	0.0099	0.0031	-	-	Remainder
35	0.127	0.065	0.100	0.0010	0.0018	0.0010	-	-	Remainder
36	0.094	0.049	0.127	0.0030	0.0048	0.0297	-	-	Remainder
37	0.144	0.091	0.040	0.0021	0.0048	0.0035	1.1	-	Remainder
38	0.019	0.047	0.155	0.0034	0.0067	0.0031	2.5	-	Remainder
39	0.020	0.005	0.039	0.0033	0.0068	0.0140	-	2.1	Remainder
40	0.152	0.082	0.180	0.0013	0.0031	0.0192	-	5.0	Remainder

[0042]

[Table 3]

(Continued in Table 4)

Alloy powder	Component composition (mass%)								
	Cr	Mo	Fe	Co	Mg	N	Mn	Si	Al
41	14.3*	14.6	2.50	1.405	0.0024	0.018	0.053	0.063	0.37
42	24.2*	14.8	2.46	0.086	0.0028	0.030	0.059	0.019	0.45
43	19.0	11.8*	0.17	0.952	0.0009	0.014	0.224	0.075	0.10
44	21.1	23.2*	5.13	1.193	0.0012	0.011	0.347	0.018	0.21
45	22.6	19.4	-*	1.849	0.0016	0.031	0.413	0.096	0.16
46	20.4	18.1	7.05*	1.432	0.0021	0.021	0.245	0.006	0.06
47	18.1	13.7	0.77	-*	0.0037	0.038	0.318	0.109	0.10
48	17.4	14.3	4.35	2.505*	0.0009	0.031	0.156	0.039	0.17
49	16.7	16.6	0.47	0.073	-	0.012	0.466	0.126	0.29
50	21.8	19.2	4.85	1.692	0.0052	0.015	0.496	0.047	0.27
51	20.7	20.0	3.47	1.551	0.0018	-	0.450	0.119	0.02
52	15.5	17.3	3.80	2.027	0.0020	0.043*	0.431	0.017	0.13
53	14.9	17.7	5.23	0.996	0.0006	0.018	0.003	0.064	0.15
54	22.2	21.9	4.27	1.017	0.0049	0.016	0.522*	0.011	0.05
55	16.3	12.9	0.54	2.172	0.0026	0.028	0.366	-*	0.33
56	21.6	22.4	5.34	1.325	0.0038	0.006	0.298	0.204*	0.42
57	14.8	18.3	0.46	0.615	0.0047	0.006	0.446	0.085	-*
58	18.2	13.7	0.58	1.870	0.0045	0.021	0.372	0.087	0.53*
59	22.3	17.7	0.53	0.550	0.0018	0.007	0.241	0.076	0.28
60	23.9	19.7	3.33	1.398	0.0039	0.038	0.304	0.019	0.47
61	21.6	19.4	5.36	1.385	0.0025	0.010	0.295	0.190	0.49
62	18.4	16.6	2.88	0.371	0.0023	0.037	0.338	0.065	0.12

63	20.3	18.8	3.71	0.176	0.0027	0.006	0.430	0.187	0.30
64	21.0	21.0	1.80	0.397	0.0045	0.028	0.215	0.184	0.28
65	21.0	19.5	2.92	1.267	0.0030	0.037	0.179	0.140	0.22
66	18.4	14.0	3.50	0.908	0.0040	0.014	0.294	0.146	0.07
67	20.5	14.3	3.82	0.513	0.0013	0.007	0.250	0.111	0.39
68	21.4	20.7	1.97	0.648	0.0036	0.002	0.161	0.133	0.04
69	19.8	18.0	0.14	2.089	0.0005	0.016	0.258	0.120	0.09
70	17.8	20.8	0.83	0.921	0.0015	0.023	0.343	0.200	0.31

(note) * indicates beyond the scope of the present invention

[0043]

[Table 4]

(Continued from Table 3)

Alloy powder	Component composition (mass%)								
	Ti	Cu	V	B	Zr	O	Ta	W	Ni+ unavoidable impurities
41	0.340	0.074	0.076	0.0027	0.0081	0.0291	-	-	Remainder
42	0.236	0.110	0.027	0.0037	0.0020	0.0196	-	-	Remainder
43	0.126	0.025	0.074	0.0004	0.0027	0.0085	-	-	Remainder
44	0.358	0.019	0.282	0.0030	0.0054	0.0193	-	-	Remainder
45	0.406	0.097	0.219	0.0003	0.0074	0.0260	-	-	Remainder
46	0.382	0.166	0.251	0.0002	0.0078	0.0110	-	-	Remainder
47	0.454	0.126	0.091	0.0003	0.0037	0.0173	-	-	Remainder
48	0.348	0.166	0.112	0.0044	0.0075	0.0158	-	-	Remainder
49	0.193	0.094	0.078	0.0025	0.0087	0.0229	-	-	Remainder
50	0.129	0.094	0.216	0.0048	0.0033	0.0059	-	-	Remainder
51	0.142	0.203	0.258	0.0014	0.0021	0.0107	-	-	Remainder
52	0.197	0.126	0.190	0.0049	0.0010	0.0136	-	-	Remainder
53	0.108	0.215	0.037	0.0025	0.0051	0.0033	-	-	Remainder
54	0.199	0.086	0.230	0.0017	0.0060	0.0106	-	-	Remainder
55	0.369	0.036	0.275	0.0006	0.0023	0.0124	-	-	Remainder
56	0.201	0.072	0.271	0.0024	0.0027	0.0083	-	-	Remainder
57	0.098	0.094	0.174	0.0004	0.0041	0.0246	-	-	Remainder
58	0.475	0.054	0.233	0.0023	0.0006	0.0162	-	-	Remainder
59	-*	0.064	0.158	0.0048	0.0071	0.0095	-	-	Remainder
60	0.505*	0.237	0.064	0.0019	0.0081	0.0192	-	-	Remainder
61	0.417	-	0.148	0.0004	0.0083	0.0125	-	-	Remainder
62	0.064	0.253*	0.045	0.0025	0.0090	0.0244	-	-	Remainder
63	0.435	0.247	-*	0.0022	0.0074	0.0168	-	-	Remainder
64	0.073	0.152	0.303*	0.0019	0.0001	0.0284	-	-	Remainder
65	0.149	0.199	0.246	-*	0.0056	0.0015	-	-	Remainder
66	0.001	0.236	0.245	0.0052*	0.0044	0.0099	-	-	Remainder
67	0.006	0.212	0.284	0.0022	-*	0.0149	-	-	Remainder
68	0.162	0.064	0.119	0.0028	0.0105	0.0222	-	-	Remainder

69	0.280	0.175	0.106	0.0033	0.0001	-*	-	-	Remainder
70	0.255	0.161	0.009	0.0026	0.0097	0.0303*	-	-	Remainder

(note) * indicates beyond the scope of the present invention

[0044]

[Powder yield (%)]

For the powder in a particle size range of 20 to 80 μm for additive manufacturing obtained by classification, the powder yield (%) was determined as the value of (a mass of powders with a particle size of 20 to 80 μm) $\times$ 100/(a mass of gas atomized powders without change).

Table 5 and Table 6 show the values of the powder yield (%). Here, the particle size distribution before classification was measured, and in powders having an excellent yield, the proportion of powders with a particle size of less than 5 μm was 10% or less, and the proportion of powders with a particle size of 5 μm or more was high according to adjustment of the composition.

[0045]

Next, according to the powder bed method (SLM) additive manufacturing device using a laser shown in Fig. 1, using Ni-based corrosion resistant alloy powders 1 to 70, 10 plates (30 $\times$ 30 $\times$ 5 mm) were prepared as evaluation additive manufacturing products for each powder.

These plates (30 $\times$ 30 $\times$ 5 mm) as the evaluation additive manufacturing products were evaluated as follows.

[0046]

[Measurement of defect rate (area%)]

A cross section of the plate (30 $\times$ 30 $\times$ 5 mm) as the evaluation additive manufacturing product was cut and embedded in a resin, and the plate was polished to #1500 with water resistant emery paper, and then additionally polished with a diamond paste having a particle size of 1 μm to achieve a mirror-finished surface.

The mirror-finished surface was observed under an optical microscope, defects (voids and nests of 1 μm square or more) within a range of 1 mm $\times$ 1 mm were identified by an image analysis device (digital microscope VHX6000: commercially available from Keyence Corporation), and the area ratio thereof was determined as a defect rate (area%).

5 Here, the resolution was 1,024 $\times$ 1,280 pixels, binarization was performed by image analysis software, and a black part of 8 or more pixels was defined as a defect.

Table 5 and Table 6 show the values of the defect rate (area%).

[0047]

[Evaluation of corrosion resistance in wet environment]

10 The surface of the plate (30 $\times$ 30 $\times$ 5 mm) as the evaluation additive manufacturing product was polished, and finally finished to #400 with water resistant emery paper. Then, electropolishing was performed, and the polished sample was kept in an ultrasonic vibration state in acetone for 5 minutes and degreased to prepare a corrosion test piece.

15 A corrosion test was performed using these corrosion test pieces in boiling 1% HCl and 35% HCl for 24 hours.

When the weight loss amount before and after the test was measured, a corrosion rate (mm/year) was calculated from the surface area before the test and the test period.

The results are shown in Table 5 and Table 6.

[0048]

20 [Evaluation of corrosion resistance with respect to semiconductor process gas]

The surface of the plate (30 $\times$ 30 $\times$ 5 mm) as the evaluation additive manufacturing product was polished, and finally finished to #400 with water resistant emery paper. Then, electropolishing was performed, and the polished sample was kept in an ultrasonic vibration state in acetone for 5 minutes and degreased to prepare a corrosion test piece.

These corrosion test pieces were placed in a small test chamber made of a Ni-based alloy (UNS N06022), the chamber was evacuated, and then filled with a corrosion gas (Cl₂, HBr, NF₃), and kept at a predetermined temperature (Cl₂: 250°C, HBr: 250°C, NF₃: 350°C) for 24 hours according to the type of the corrosion gas, and the temperature was then cooled to room temperature, replacement with argon gas was performed and the sample was then quickly stored in a vacuum desiccator.

The corrosion test pieces were sequentially subjected to SEM observation, and an area ratio of the corroded part observed in an island shape from the captured image was measured by image analysis software (winRoof2015).

Here, the resolution was $1,024 \times 1,280$, and the magnification was 500, and an area of 8 pixels or more was defined as a corroded area.

The results are shown in Table 5 and Table 6.

Here, for the comparative alloy powders with a low powder yield or a high defect rate, corrosion test pieces were not prepared and no corrosion resistance evaluation was performed.

[0049]

[Table 5]

Alloy powder	Powder yield (%)	Defect rate (area%)	Corrosion resistance in wet environment (corrosion rate, (mm/year)		Corrosion resistance with respect to halogen-containing gas (area ratio% of corroded part)			Note
			1% HCl	35% HCl	Cl ₂	HBr	NF ₃	
1	33.7	0.5	0.01	0.11	0.35	0.47	0.43	
2	40.9	0.4	0.13	0.13	2.55	0.40	2.34	
3	40.0	0.3	0.45	0.15	3.26	0.94	3.79	
4	37.0	0.7	0.15	0.18	3.84	4.87	2.53	
5	34.2	0.7	0.03	0.16	4.78	3.28	4.63	
6	40.1	0.7	0.08	0.12	0.45	2.83	3.00	
7	39.2	0.4	0.08	0.16	0.93	2.87	3.85	
8	34.6	0.5	0.06	0.13	0.38	2.28	4.64	
9	38.2	0.9	0.06	0.26	3.57	2.37	3.23	
10	41.8	0.6	0.01	0.10	3.78	2.82	2.98	

11	40.3	0.6	0.21	0.18	0.36	0.68	4.60	
12	38.0	0.4	0.16	0.17	0.42	1.81	4.35	
13	37.0	0.9	0.17	0.02	4.81	3.07	1.50	
14	38.1	0.4	0.07	0.26	1.34	4.84	2.09	
15	37.3	0.6	0.11	0.02	0.99	3.75	4.60	
16	38.8	0.7	0.18	0.05	2.39	3.19	1.01	
17	37.3	0.4	0.04	0.02	1.01	2.42	0.99	
18	37.9	0.4	0.13	0.05	2.03	3.65	4.48	
19	37.0	0.6	0.01	0.04	4.15	1.49	2.32	
20	36.2	0.3	0.11	0.19	4.95	2.39	0.96	
21	39.1	0.4	0.08	0.08	1.83	3.50	2.29	
22	40.6	0.4	0.11	0.08	4.72	3.51	2.93	
23	40.8	0.4	0.03	0.11	2.93	3.68	2.16	
24	38.2	0.2	0.05	0.19	1.21	2.15	0.35	
25	40.4	0.5	0.01	0.20	1.51	4.35	1.32	
26	40.2	0.8	0.01	0.13	2.87	3.36	1.27	
27	41.0	0.8	0.11	0.11	2.58	1.23	2.80	
28	36.6	0.4	0.06	0.23	3.91	4.68	0.73	
29	35.3	0.3	0.07	0.05	0.54	1.02	4.68	
30	37.2	0.9	0.15	0.07	4.05	4.63	1.64	
31	40.7	0.8	0.02	0.19	3.55	2.36	1.05	
32	36.0	0.3	0.21	0.07	4.64	4.78	4.72	
33	36.4	0.9	0.11	0.07	4.84	3.12	2.49	
34	40.6	0.6	0.13	0.15	1.61	3.54	3.80	
35	35.8	0.6	0.03	0.19	3.33	2.15	3.18	
36	39.6	0.7	0.20	0.02	0.37	4.34	3.89	
37	35.5	0.5	0.15	0.13	1.76	4.41	0.52	
38	42.4	0.9	0.07	0.10	0.53	0.87	1.25	
39	40.0	0.6	0.12	0.12	0.74	0.41	0.99	
40	39.7	0.9	0.41	0.14	1.98	2.99	1.83	

[0050]

[Table 6]

Alloy powder	Powder yield (%)	Defect rate (area%)	Corrosion resistance in wet environment (corrosion rate, (mm/year)		Corrosion resistance with respect to halogen-containing gas (area ratio% of corroded part)			Note
			1% HCl	35% HCl	Cl ₂	HBr	NF ₃	
41	39.8	0.7	0.56	0.32	7.26	6.35	5.74	
42	36.2	0.3	0.53	0.33	7.36	7.23	8.32	
43	38.9	0.6	0.66	0.29	8.55	5.33	6.21	
44	41.6	1.4	-	-	-	-	-	Large defect
45	28.9	1.0	-	-	-	-	-	Poor yield

46	42.5	0.9	0.75	0.44	6.52	4.53	5.33	
47	27.5	0.4	-	-	-	-	-	Poor yield
48	28.1	0.6	-	-	-	-	-	Poor yield
49	40.2	0.5	0.23	0.11	5.67	3.28	4.44	
50	42.9	1.0	0.16	0.23	2.67	6.57	8.32	
51	39.1	0.6	0.17	0.21	3.88	5.78	5.99	
52	39.5	1.7	-	-	-	-	-	Large defect
53	41.5	0.5	0.08	0.02	5.48	3.29	6.66	
54	42.5	0.7	0.55	0.37	5.26	7.62	6.27	
55	36.1	1.4	-	-	-	-	-	Large defect
56	40.3	0.8	0.52	0.28	5.16	7.03	8.68	
57	36.4	1.6	-	-	-	-	-	Large defect
58	39.5	2.3	-	-	-	-	-	Large defect
59	40.9	1.2	-	-	-	-	-	Large defect
60	36.5	1.4	-	-	-	-	-	Large defect
61	40.7	0.8	0.09	0.16	5.78	6.32	6.47	
62	37.8	1.5	-	-	-	-	-	Large defect
63	28.8	0.7	-	-	-	-	-	Poor yield
64	23.7	0.6	-	-	-	-	-	Poor yield
65	39.9	1.3	-	-	-	-	-	Large defect
66	37.5	0.9	0.14	0.28	6.24	5.87	7.21	
67	37.9	1.4	-	-	-	-	-	Large defect
68	38.0	0.4	0.16	0.12	7.21	6.93	8.56	
69	36.6	1.3	-	-	-	-	-	Large defect
70	34.6	1.6	-	-	-	-	-	Large defect

[0051]

As can be clearly understood from the results shown in Table 5 and Table 6, it was confirmed that, in the Ni-based corrosion resistant alloy powder for additive manufacturing having the composition according to the present invention, all the manufacturing yield, the

defect rate of the additive manufacturing product produced using this powder, and the corrosion resistance (wet environment or semiconductor process gas) were better than those of the Ni-based corrosion resistant alloy powder for additive manufacturing outside the present invention and the additive manufacturing product produced using this powder. In addition, it was confirmed that, when a more preferable composition was used, high corrosion resistance was exhibited even under a corrosive environment with a semiconductor process gas.

[0052]

(Example 2)

Samples with different particle size distributions were prepared for the No.1 alloy powder from the Ni-based corrosion resistant alloy powders for additive manufacturing having the above component compositions, and d10, d50, and d90 were measured using a laser diffraction type particle size distribution measurement device (SALD-2300: commercially available from SHIMADZU). In addition, the uniformity represented by $(d90-d10)/d50$ was determined.

In addition, the repose angle of these samples was measured according to JIS R9301-2-2. Specifically, using a repose angle measurement instrument (ASK-01), the sample was supplied to a saucer, and the angle of the formed mountain was measured.

Spreading properties when these Ni-based corrosion resistant alloy powders were supplied onto the bed and squeezed to form a powder layer having a thickness of 40 to 60 μm were evaluated. For the spreading properties, according to visual inspection, if the powders were spread to a uniform thickness, the spreading properties were regarded as “good,” and if the powder layer was frayed and biased, the coatability was regarded as not good “NG.”

The results are shown in Table 7.

[0053]

[Table 7]

Sample No.	Repose angle (degrees)	Spreading properties	Particle size distribution			Uniformity
			d ₁₀	d ₅₀	d ₉₀	
2-1*	55.3	NG	0.6	4.3	16.3	3.7
2-2*	51.4	NG	2.4	8.4	24.3	2.6
2-3	46.2	Good	7.5	12.5	25.1	1.4
2-4	36.8	Good	19.5	37.6	57.1	1.0
2-5	32.3	Good	32.8	58.6	97.4	1.1
2-6*	48.4	NG	19.3	52.4	110.8	1.7

* indicates beyond the scope of the present invention

[0054]

Based on Table 7, in the Ni-based corrosion resistant alloy powder for additive manufacturing of the present invention, when the repose angle exceeded 48.0 degrees, the spreading properties were poor. Therefore, it was confirmed that spreading properties were improved at 48.0 degrees or less, and the alloy powder at 46.2 degrees or less had good spreading properties. In addition, it was found that the repose angle differed depending on the particle size distribution. Here, the alloy powder within the particle size distribution range of the present invention had good spreading properties. In addition, the uniformity was within 1.5 or less, and good results were obtained at 1.4 or less.

As described above, it is possible to obtain an additive manufacturing product having a low defect rate using these Ni-based corrosion resistant alloy powders.

[Industrial Applicability]

[0055]

When the Ni-based corrosion resistant alloy powder of the invention is used as a raw material powder for additive manufacturing, an additive manufacturing product having excellent corrosion resistance and very few defects can be obtained. For example, it is possible to provide a member for semiconductor manufacturing device made of an additive manufacturing product, but it is expected to be applied as a corrosion resistant metal powder for additive manufacturing of a member having a complex shape not only for a member for semiconductor

manufacturing device, but also in a wide range of fields such as chemical plants, pharmaceutical manufacturing facilities, and oil and gas fields.

[CLAIMS]

[Claim 1]

A Ni-based corrosion resistant alloy powder for additive manufacturing, composed of a powder of a Ni-based alloy having a component composition including,

- 5 in mass%,
Cr: 14.5 to 24.5%,
Mo: 12.0 to 23.0%,
Fe: 0.01 to 7.00%,
Co: 0.001 to 2.500%,
10 Mg: 0.010% or less,
N: 0.040% or less,
Mn: 0.001 to 0.50%,
Si: 0.001 to 0.200%,
Al: more than 0 and 0.50% or less,
15 Ti: 0.001 to 0.500%,
Cu: 0.250% or less,
V: 0.001 to 0.300%,
B: 0.0001 to 0.0050%,
Zr: 0.0001 to 0.0200%, and
20 O: 0.0010 to 0.0300%,

with the remainder being Ni and unavoidable impurities,

wherein C, S and P are contained as the unavoidable impurities (C: less than 0.05%, S: less than 0.01% and P: less than 0.01%), and

wherein a repose angle of the Ni-based alloy powder is 48 degrees or less.

25 [Claim 2]

The Ni-based corrosion resistant alloy powder for additive manufacturing according to claim 1,

wherein, in the Ni-based alloy powder, in a cumulative distribution curve showing the relationship between a particle size and a cumulative volume from a small particle size side

5 obtained by a laser diffraction method,

a particle size d10 corresponding to a cumulative frequency of 10 volume% of the powder is 7 μm or more and 35 μm or less,

a particle size d50 corresponding to a cumulative frequency of 50 volume% of the powder is 10 μm or more and 60 μm or less, and

10 a particle size d90 corresponding to a cumulative frequency of 90 volume% of the powder is 20 μm or more and 98 μm or less.

[Claim 3]

The Ni-based corrosion resistant alloy powder for additive manufacturing according to claim 2,

15 wherein, in the cumulative distribution curve, the uniformity represented by $(d90-d10)/d50$ is 1.5 or less.

[Claim 4]

The Ni-based corrosion resistant alloy powder for additive manufacturing according to any one of claims 1 to 3,

20 wherein the component composition of the Ni-based alloy further includes Ta: 2.5% or less.

[Claim 5]

The Ni-based corrosion resistant alloy powder for additive manufacturing according to any one of claims 1 to 3,

wherein the component composition of the Ni-based alloy further includes W: 5.0% or less.

[Claim 6]

5 A method of manufacturing an additive manufacturing product, comprising
performing additive manufacturing using the Ni-based corrosion resistant alloy powder
for additive manufacturing according to any one of claims 1 to 5 as a raw material powder.

[Claim 7]

The method of manufacturing an additive manufacturing product according to claim 6,
wherein the additive manufacturing product is a member for semiconductor
10 manufacturing device.

[Claim 8]

The method of manufacturing an additive manufacturing product according to claim 6
or 7,
wherein the additive manufacturing is a powder bed fusion method.

15